REMARKS

Applicants wish to thank Examiner Kiliman for the helpful and courteous discussion with Applicants' Representative on January 25, 2005. As discussed, Applicants submit herewith a corrected Terminal Disclaimer.

In addition, also as discussed, Applicants submit Certified English Translations of the Japanese priority documents of the present invention, JP 2000-256775 and JP 2000-262611, filed August 28 and 31, 2000, respectively. Applicants have thus perfected their claim to priority. This also removes the corresponding Japanese and European applications of US 6,534176 (filed December 6, 2000) as well as the US patent as prior art references. JP 2001-163613 published June 19, 2001, and EP 1106574 published June 13, 2001. See the attached Derwent Search Report for the publication dates.

This amendment was not earlier presented because the error was not earlier detected.

Applicants submit that the amendment does not require further search or consideration. No new matter has been added. Entry and favorable consideration are respectfully requested.

Applicants submit that the present application remains in condition for allowance and the Examiner is requested to pass this case to Issue.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,

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NFO:KAG:

us6534176/pn

2004 THOMSON DERWENT on STN ANSWER 1 OF 1 WPINDEX L1

2001-354307 [37] WPINDEX ACCESSION NUMBER:

DOC. NO. CPI:

C2001-109748

Laminated scaly silica particles, useful in adhesives and TITLE:

for forming heat insulating coatings, consist of secondary particles of foliar silica overlaid one on

another and aligned face-to-face in parallel.

A60 E36 DERWENT CLASS:

FUJII, A; INOUE, M; MINOHARA, S; OHBA, Y; SASAKI, T; INVENTOR (S):

TERASE, K

(ASAG) ASAHI GLASS CO LTD; (DOHK-N) DOHKAI CHEM IND CO PATENT ASSIGNEE(S):

LTD; (DOKA-N) DOKAI KAGAKU KOGYO KK

COUNTRY COUNT:

PATENT INFORMATION:

PG MAIN IPC PATENT NO KIND DATE WEEK LA_____

38 C08K009-08 US 2001003358 A1 20010614 (200137)* JP 2001163613 A 20010619 (200140) 26 C01B033-12

A1 20010613 (200141) EN C01B033-12 R: AL AT BE CH CY DE DK ES FI FR GB GR IE IT LI LT LU LV MC MK NL PT

RO SE SI TR

14 C09D201-00 JP 2002030251 A 20020131 (200212)

C09C001-04 <--B2 20030318 (200322) US 6534176

B1 20040303 (200417) EN C01B033-12 EP 1106574

R: CH DE FR GB IT LI NL

APPLICATION DETAILS:

		IND		PLICATION	DATE
	2001003358			2000-729822	20001206
JР	2001163613	A	JP	1999-351182	19991210
EP	1106574	A1	ΕP	2000-126481	20001207
JP	2002030251	A	JP	2000-206264	20000707
US	6534176	B2	US	2000-729822	20001206
ΕP	1106574	B1	EP	2000-126481	20001207

PRIORITY APPLN. INFO: JP 2000-206264 20000707; JP 1999-351182

19991210; JP 2000-139659 20000512

INT. PATENT CLASSIF.:

C01B033-12; C08K009-08; C09C001-04; C09D201-00 MAIN:

B32B005-16; C08J009-32; C08K003-36; C08K007-00; SECONDARY:

C08L101-16; C09D001-00; C09D007-12; C09J011-04